

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Masatomo Shibata et al.

Examiner: Trang Q. Tran

Appl. No: 10/519,152

Art Unit: 2811

Filed: August 10, 2005

Docket: 23165

For: POROUS SUBSTRATE AND ITS MANUFACTURING METHOD, AND GAN
SEMICONDUCTOR MULTILAYER SUBSTRATE AND ITS MANUFACTURING
METHOD

Confirmation No: 5477

Date: July 15, 2009

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE UNDER 37 C.F.R. § 1.111

Sir:

The Applicant has filed this Response pursuant to 37 C.F.R. § 1.111 in reply to the outstanding Official Action dated September 11, 2008, and the Applicant believes the Response to be fully responsive to the Official Action for reasons set forth below.

CERTIFICATE OF ELECTRONIC FILING

I hereby certify that this correspondence is being deposited with the United States Patent & Trademark Office via Electronic Filing through the United States Patent and Trademark Office e-business website, on July 15, 2009.

Dated: July 15, 2009



Paul J. Esatto, Jr.